

ABSTRACT

A ceramic heater improving a uniformity of temperature distribution in a work heating face, wherein a resistance heating body formed on a face of a ceramic substrate opposite to the work heating face thereof is such that the scattering of thickness is within $\pm 50\%$ of an average thickness, and a surface roughness of the resistance heating body is a range of $0.05-100\text{ }\mu\text{m}$ as R_{max} and not more than 50% of the average thickness.